

# Germanium Tetrafluoride, GeF<sub>4</sub>

## Description

Germanium Tetrafluoride (GeF<sub>4</sub>) is a colorless, toxic gas with a pungent odor. In the semiconductor industry, GeF<sub>4</sub> is used for ion implantation.

Properties	Units	Specifications
Germanium Tetrafluoride, GeF <sub>4</sub>		99.999%
Hydrogen Fluoride, HF	(ppmv)	<5
Carbon Dioxide, CO <sub>2</sub>	(ppmv)	<5
Oxygen/Argon, O <sub>2</sub> / Ar	(ppmv)	<3
Nitrogen, N <sub>2</sub>	(ppmv)	<3

For specific values or requirements, please contact us.

## About Inhance Technologies

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For more than 40 years, Inhance Technologies' world-class experts have been collaborating with customers globally to create customized solutions and offer exclusive technologies.